L Number	Hits	Search Text	DB	Time stamp
_	10	(("5595922") or ("5679968") or ("5681768") or ("5314834")).PN.	USPAT; US-PGPUB;	2003/02/07 14:41
-	1464	(438/587,275,911,981,595).CCLS.	EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO;	2001/10/05
-	660	(257/324,340,389).CCLS.	DERWENT; IBM_/DB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/05 10:33
_	102	(kurt with eaton).xa.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/05
-	40	(("4098618") or ("4789883") or ("4885259") or ("4912062") or ("5077230") or ("5208175") or ("5358894") or ("5360751") or ("5550070") or ("5592415")	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/05
-	4313	or ("5595922") or ("5599731") or ("5648287") or ("5680345")).PN. ((438/264,265,911,440,407,257,211) or (29/25.01) or (257/315)).CCLS.	<pre>IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;</pre>	2001/10/09 08:44
-	17	(("5229311") or ("5374847") or ("5972751") or ("6069041") or ("6146946") or ("6184088") or ("6190973") or ("6207506")).PN.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/09 08:33
_	10798	source and drain and implant	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/09 08:45
-	3665	(source and drain and implant) and (gate and (sidewall or (side adj wall)))	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2001/10/09 08:56
-	1109	((source and drain and implant) and (gate and (sidewall or (side adj wall)))) and impurities	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/10/09 09:06
-	622	(((source and drain and implant) and (gate and (sidewall or (side adj wall)))) and impurities) and spacers	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/10/09 09:06
-	233	<pre>((((source and drain and implant) and (gate and (sidewall or (side adj wall)))) and impurities) and spacers) and (active with region)</pre>	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2001/10/09 09:07
_	1	("6271572").PN.	USPĀT	2002/05/28
_	9	(("4978628") or ("5254487") or ("5314834") or ("5472887") or ("5480828") or ("5679968") or ("5681768") or ("5858827") or ("6093950")).PN.	USPAT	2002/05/28

· 57 .

-	371	((gate near electrode) with (dopant or	USPAT;	2003/02/07
		doped or doping or impurity or	EPO; JPO;	13:35
		impurities)) same (active near regions)	IBM TDB	
-	3065	((438/217) or (438/231) or (438/275) or	USPAT;	2003/02/07
Į.		(438/301)).CCLS.	US-PGPUB;	14:41
			EPO; JPO;	1
	-		DERWENT;	
			IBM TDB	
-	341	(((438/217) or (438/231) or (438/275) or	USPAT;	2003/02/07
		(438/301)).CCLS.) and (voltage with (gate	US-PGPUB;	14:43
	İ	near electrode))	EPO; JPO;]
		11042 02002040//	DERWENT;	1
			IBM TDB	j i
_	1995	(((438/217) or (438/231) or (438/275) or	USPAT;	2003/02/07
	1995	(438/301)).CCLS.) not (@ad>19970212 or	US-PGPUB;	14:45
		(436/301)).CCLS.) NOT (Gad>199/0212 OF CTLate Grad>199/0212 OF CTLate Grad>199/0212 OF CTLate Gad>199/0212 OF CTLAT	EPO; JPO;	11.40
		GIIAU/199/0212/	DERWENT;	
	464	////439/317\ am /439/331\ am /439/375\	IBM_TDB	2002/02/07
-	464	((((438/217) or (438/231) or (438/275) or (438/301)).CCLS.) not (@ad>19970212 or	USPAT;	2003/02/07
			US-PGPUB;	14:46
		@rlad>19970212)) and ((gate near	EPO; JPO;	
		electrode) with (doped or dope or	DERWENT;	
		impurity or impurites or implant or	IBM_TDB	1
		implanted or implanting or doping))		2222 (22 (27
-	294	((((438/217) or (438/231) or (438/275) or	USPAT;	2003/02/07
	Į	(438/301)).CCLS.) not (@ad>19970212 or	US-PGPUB;	14:52
		@rlad>19970212)) and ((gate near	EPO; JPO;	
		electrode) with (doped or dope or	DERWENT;	
		impurity or impurites or implant or	IBM_TDB	
		implanted or implanting or doping)) and		1
		voltage		
-	2947	((257/392) or (257/402) or (257/399) or	USPAT;	2003/02/07
	İ	(257/369) or (257/372)).CCLS.	US-PGPUB;	14:53
	1		EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	2371	(((257/392) or (257/402) or (257/399) or	USPAT;	2003/02/07
		(257/369) or (257/372)).CCLS.) not	US-PGPUB;	14:54
		(@ad>19970212 or @rlad>19970212)	EPO; JPO;	
			DERWENT;	
			IBM TDB	
_	304	((((257/392) or (257/402) or (257/399) or	USPAT;	2003/02/07
		(257/369) or (257/372)).CCLS.) not	US-PGPUB;	14:56
		(@ad>19970212 or @rlad>19970212)) and	EPO; JPO;	
		((gate near electrode) with (doping or	DERWENT;	
		dopant or doped or dope or impurities or	IBM TDB	
		impurity or implant or implanting or		
		implanted)) and voltage		(
		· · · · · · · · · · · · · · · · · · ·		